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P/1250-272

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Tadashi MAEGAWA, et al.

Date: June 22, 2004

Serial No.: 10/789,870

Group Art Unit: 2812

Filed: February 26, 2004

Examiner:

For: SUBSTRATE PROCESSING APPARATUS

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

SUBMISSION

Sir:

Submitted herewith is a copy of art together with a form listing the same for the convenience of the Examiner.

Respectfully submitted,

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on June 22, 2004

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Name of applicant, assignee or  
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Signature

June 22, 2004

Date of Signature

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<b>APPLICANT'S ART CITATION</b> (Use several sheets if necessary)		Application <b>10/789,870</b>		OFGS File No. <b>P/1250-272</b>	
		Applicant <b>Tadashi MAEGAWA et al</b>			
		Filing Date <b>February 26, 2004</b>		Group Art Unit <b>2812</b>	

NOT RECORDED  
 JUN 25 2004  
 PATENT & TRADEMARK OFFICE 096

U.S. PATENT DOCUMENTS						
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-					
	US-					
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FOREIGN PATENT DOCUMENTS							
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
	11-268827	10-1999	Japan			Description only	
	11-274271	10-1999	Japan			Description only	
	11-260-886	9-1999	Japan			Abstract only	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)		

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